

Form PTO-1449

U.S. Department of Commerce
Patent and Trademark OfficeAtty. Docket No.
0073/65994Serial No.
09/937,976INFORMATION DISCLOSURE CITATION
BY APPLICANT
(Use several sheets if necessary)Applicant
Mark Russell ATTIEHFiling Date
September 28,
2001Group
3621

U.S. PATENT DOCUMENTS

| Examiner Initial | | Document Number | | | | | | | Date | Name | Class | Subclass | Filing Date if Appropriate |
|------------------|----|-----------------|---|---|---|---|---|---|---------------|---------------|-------|----------|----------------------------|
| /JW/ | AA | 5 | 2 | 2 | 1 | 8 | 3 | 8 | June 22, 1993 | Gutman et al. | | | |
| | AB | | | | | | | | | | | | |
| | AC | | | | | | | | | | | | |
| | AD | | | | | | | | | | | | |
| | AE | | | | | | | | | | | | |
| | AF | | | | | | | | | | | | |
| | AG | | | | | | | | | | | | |
| | AH | | | | | | | | | | | | |

FOREIGN PATENT DOCUMENTS

| | | | Document Number | | | | | | Date | Country | Class | Subclass | Translation | | |
|--|--|----|-----------------|----|---|---|---|---|------|------------------|-------|----------|-------------|-------|--|
| | | | | | | | | | | | | | Yes | No | |
| | | AI | WO | 96 | 1 | 3 | 8 | 1 | 4 | May 9, 1996 | PCT | | | ABST. | |
| | | AJ | WO | 97 | 4 | 5 | 8 | 1 | 4 | December 4, 1997 | PCT | | | ABST. | |
| | | AK | WO | 98 | 4 | 2 | 1 | 7 | 3 | October 1, 1998 | PCT | | | ABST. | |
| | | AL | WO | 98 | 3 | 4 | 2 | 0 | 3 | August 6, 1998 | PCT | | | ABST. | |
| | | AM | | | | | | | | | | | | | |
| | | AN | | | | | | | | | | | | | |
| | | AO | | | | | | | | | | | | | |
| | | AP | | | | | | | | | | | | | |
| | | AQ | | | | | | | | | | | | | |

| | | | |
|----------|---------------|-----------------|---------------|
| EXAMINER | /John Winter/ | DATE CONSIDERED | /John Winter/ |
|----------|---------------|-----------------|---------------|

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609: Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.